Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1.-12. (Canceled)

13. (Previously Presented) A device formed by a first body and a second body welded together through a mechanical and electrical connection structure, comprising:

an electrically conductive region welded between said first body and said second body; and

- a spacing region arranged near said electrically conductive region and surrounding an active region.
- 14. (Original) The device according to claim 13, wherein said electrically conductive region is of a low-melting eutectic material.
- 15. (Original) The device according to claim 14, wherein said low-melting eutectic material is formed by alternating layers of gold and tin.
- 16. (Original) The device according to claim 13, wherein said spacing region is of dielectric material.
- 17. (Original) The device according to claim 16, wherein said dielectric material is chosen from among a spun polymer, such as SU8, polyimide, a composite material formed by laminated polymer layers, such as a photosensitive stick foil, and oxynitrides.

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- 18. (Original) The device according to claim 13, wherein said spacing region forms a delimiting cavity surrounding said electrically conductive region.
- 19. (Previously Presented) The device according to claim 13, further comprising a metal region which extends on top of said second body and beneath said electrically conductive region.
- 20. (Original) The device according to claim 19, wherein said welding region and said metal region are of a material chosen from among titanium, gold and nickel.

21.-26. (Canceled)

- 27. (Previously Presented) A device comprising:
- a first body of semiconductor material;
- a first metal region, formed on a first surface of the first body;
- a second body of semiconductor material spaced apart from the first body;
- a spacer separating the first and second body and in contact with the first surface of the first body and a first surface of the second body, the spacer defining an enclosed space between the first and second bodies;
 - a second metal region, formed on a first surface of the second body; and
- a connection structure bonded to the first and second metal regions, forming thereby an electrical connection between the first and second metal regions.
- 28. (Original) The device of claim 27 wherein the connection structure is a low-melting eutetic material welded to the first and second metal regions.
- 29. (Previously Presented) The device of claim 27 wherein, the first and second metal regions and the connection structure are formed within the enclosed space defined by the spacer.

- 30. (Previously Presented) The device of claim 27 wherein a micromechanical structure is formed within the enclosed space defined by the spacer.
- 31. (Original) The device of claim 27 wherein the first body of semiconductor material is formed of quartz.
- 32. (Original) The device of claim 31, further comprising a mirror formed on a second surface of the first body.
- 33. (Original) The device of claim 31, further comprising a diffractive lens formed on the second surface of the first body.
- 34. (Previously Presented) The device of claim 13 wherein the device comprises an electromechanical, fluid and optical system.
- 35. (Previously Presented) The device of claim 13, wherein the active region comprises an electromechanical structure.
- 36. (Previously Presented) The device of claim 13, wherein the active region comprises an optical structure.
- 37. (Previously Presented) The device of claim 36, further comprising a mirror formed on a surface of the first body opposite the optical structure.
- 38. (Previously Presented) The device of claim 36, further comprising:
 a third body welded to the first body adjacent to the second body; and
 a spacing region formed between the first and third bodies and surrounding an additional active region.

- 39. (Previously Presented) The device of claim 38, further comprising first and second mirrors formed on opposite faces of the first body.
- 40. (Previously Presented) The device of claim 13 wherein the first and second bodies are wafers of semiconductor material.
- 41. (Previously Presented) The device of claim 13 wherein the spacing region completely surrounds the active region.
- 42. (New) A device formed by a first body and a second body welded together through a mechanical and electrical connection structure, comprising:

an electrically conductive region welded between said first body and said second body; and

- a spacing region arranged near said electrically conductive region and surrounding a majority of an active region.
- 43. (New) A device formed by a first body and a second body welded together through a mechanical and electrical connection structure, comprising:

an electrically conductive region welded between said first body and said second body; and

- a spacing region arranged near said electrically conductive region and surrounding more than half of an active region.
- 44. (New) A device formed by a first body and a second body welded together through a mechanical and electrical connection structure, comprising:

an electrically conductive region welded between said first body and said second body; and

a spacing region arranged near said electrically conductive region and surrounding at least three sides an active region.

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45. (New) A device formed by a first body and a second body welded together through a mechanical and electrical connection structure, comprising:

an electrically conductive region welded between said first body and said second body; and

a spacing region arranged near said electrically conductive region and surrounding at least two contiguous sides of an active region.